The Delta Kappa Gamma Society International Chi State Scholarships Committee Award Application Information

A. Available Awards

- 1. At least two (2) Leadership Retreat Awards will be given each year
- 2. At least two (2) Legislative Study Session Awards will be given:
 - a. The Jacqueline Multanen Legislative Study Session Award (odd years)
 - b. The Angela Aschbrenner Award to attend the National Legislative Study Session (even years)
- 3. At least two (2) Continuing Education Awards will be given each year
- 4. One Outstanding Student Teacher Award will be given each year per Area

B. Eligibility and factors to be considered

- 1. Membership in The Delta Kappa Gamma Society International
- 2. Initiated at least two years prior to date of application
- 3. Contributions that demonstrate commitment to foster goals of The Delta Kappa Gamma Society International
- 4. Professional contributions to education and to the community
- 5. Recipient can receive the same award only once in a three year period
- Participation in the Continuing Education experience must take place between the period following notification of the award and June 30 of the following year

C. Application Process

- 1. Obtain application from Chi State website
- 2. Request that the Chapter President complete and send in the necessary recommendation form for the Continuing Education Award
- 3. Application must be postmarked by designated date
- 4. Applicants will be notified of the Scholarship Committee's decision

D. Method of Payment

- Recipients of the Chi State Study Session Awards will receive reimbursement when receipt(s) that verify participation are sent to the Scholarships Committee Chairman
- 2. Disbursement of the stipend for the Continuing Education Awards is made when verification of the project participation is sent to the Scholarships Committee Chairman (Some forms of verification may be receipts, certificates, transcripts, and proof of attendance from the professor/instructor)

E. Amount of Stipend

- 1. Leadership Retreat amount shall cover at least registration
- 2. Legislative Study Session amount shall cover at least registration
- 3. Continuing Education Award amount shall be at least \$300

<u>Purpose V:</u> To endow scholarships to aid outstanding women educators in pursuing graduate study

International Scholarships: For members in good standing for at least 3 years

- Doctorate \$10,000. Download applications from website: www.dkg.org
- Applications are due by February 1

Chi State Scholarships: For members in good standing for at least 2 years

- Doctorate \$4,000
- Master's \$2,000
- Applications can be obtained from the Chi State website: www.chistateca.org
- Applications must be postmarked on or before **December 31**

Chi State Awards: For members in good standing for at least 2 years

- Leadership Retreat Awards cover at least the cost of registration.
 Applications are due by December 31
- Continuing Education Awards are given for attendance at workshops, seminars, conferences, professional training, etc. The amount of the award is at least \$300. Applications may be turned in any time during a given year and are reviewed by the Committee in June and January. Applications for a given year are due by June 1 or December 31
- Legislative Study Session Awards are given during **odd numbered** years. The award covers at least the registration fees. Applications (along with a copy of the completed registration form) are due by **March 15.**

<u>Timeline for International and Chi State Scholarship:</u>

September - November Send for transcripts

Request letters of recommendation Complete the application form

December Postmark application packet by December 31

January Scholarship Committee reviews applications, selects and notifies

recipients. Chapter presidents will be notified.

February International Scholarship applications due February 1

Scholarship recipients are notified

May Scholarship winners are recognized at Chi State Convention

Ongoing Recipients will share with Chi State members at Chapter meetings

and Conventions to motivate others to apply